
□ Method and apparatus for **cleaning** reverse-osmosis
membrane modules.

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PA Mitsubishi Heavy Industries, Ltd., Japan
SO Jpn. Kokai Tokkyo Koho, 5 pp.
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	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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PI	JP 11104636	A2	19990420	JP 1997-275389	19971008
AB	The title method is characterized by using pressurized gas and liq. 2 phase flow for backwashing reverse-osmosis membrane modules. A pressurized gas is intermittently supplied to a pressurized liq. phase flow for backwashing reverse-osmosis membrane modules. The app. include a pressurized water supply means, and a gas supply means for supplying a compressed gas to the pressurized water supply means. The reverse-osmosis membrane modules are used for desalination of seawater, etc.				
